

# ADVANCED METAHEURISTIC ALGORITHMS FOR LASER OPTIMIZATION

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A laser is one of the most important experimental tools. In synchrotron radiation field, lasers are widely used for experiments with Pump-Probe techniques. Especially for X-ray-FELs, a laser has important roles as a seed light source or photo-cathode-illuminating light source to generate a high brightness electron bunch. The controls of laser pulse characteristics are required for many kinds of experiments. However, the laser should be tuned and customized for each requirement by laser experts. The automatic tuning of laser is required to realize with some sophisticated algorithms. The metaheuristic algorithm is one of the useful candidates to find one of the best solutions as acceptable as possible. The metaheuristic laser tuning system is expected to save our human resources and time for the laser preparations. I have shown successful results on a metaheuristic algorithm based on a genetic algorithm to optimize spatial (transverse) laser profiles and a hill climbing method extended with a fuzzy set theory to choose one of the best laser alignments automatically for each experimental requirement.

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## 1. Introduction

A laser pulse is characterized in its pulse energy, pulse chirp, spectral distributions (both of intensity and phase), 3D-profile (both of spatial and temporal), wavefront distortion,  $M^2$ -value, pointing stability, timing jitter, etc. When we use a laser on our own purposes, we have to optimize some of these laser characteristics at the same time. However, these laser pulse characteristics are not perfectly independent of each other. In this case, it is almost impossible to determine the best solution uniquely by mathematical formulae. The metaheuristic algorithm is powerful methodology to find some of the acceptable and the most preferable solutions with searching better parameters. Many kinds of metaheuristic algorithms have been proposed and applied widely. I utilized a genetic algorithm [1] and a simulated annealing method [2] to optimize 3D laser pulse shape, and a hill climbing method with a fuzzy set theory [3] to align a laser to reliable path for each experiment at advanced photoinjector test facility in SPring-8.

Applying any kind of metaheuristic algorithm, a great number of system's parameter must be introduced. Making the probability higher to find some solutions as good as possible, it is necessary to increase freedom of its searching space. For instance, optimizing laser shape, I introduced adaptive optics to increase the parameters of laser system as shown in Fig. 1 (Deformable Mirror (DM) [1] for spatial (transverse) shaping & glass (fused silica)- plate-based Spatial Light Modulator (SLM) [4] for temporal (longitudinal) shaping).

In this paper, I review mainly adaptive optical system developed with metaheuristic algorithms for controlling 3D laser pulse shape and laser alignment. I completed system to manipulate 3D laser pulse shape as an illuminating light source for a photo-cathode RF gun [5]. In low-emittance electron beam generation, the experimental requirements for laser spot size on the

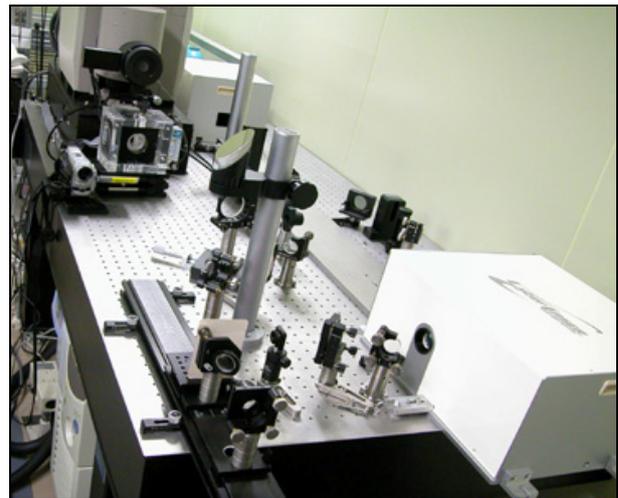


Figure 1. Adaptive-optic complex [4] for shaping both spatial and temporal laser profiles in Photo-cathode test facility at SPring-8 (Spatial shaping: DM as an adaptive actuator & UV-CCD camera (laser profiler) as a monitor; Temporal shaping: SLM with a grating pair as an adaptive actuator & Streak Camera (Fesca-200; Hamamatsu Photonics K.K.) as a monitor).

cathode should be optimized for all bunch charge densities. Therefore, I decided to develop an adaptive shaping system in spatial shaping. Note that the latest 3D UV-laser pulse shaping system was completed with a DM (transverse: 2D) assisted by a genetic algorithm and a chirped pulse stacker (longitudinal: 1D) [5]. The shape and pulse duration of the original micro chirped pulse of this pulse stacker is precisely optimized with DAZZLER (acousto-optic programmable dispersive filter (AOPDF)) in our present 3D pulse shaping system. On the other hand, a simulated annealing method was developed to optimize square laser pulses with the glass (fused silica)-

plate-based SLM [5]. However, our development of this SLM for adaptive square shaping (up to 20 ps) in high energy (~ mJ) UV-pulse was discontinued in 2005. It could be operated as a square pulse shaper even for the cw-mode. The operation with high repetition rate is attractive for X-ray Free Electron Laser (XFEL) [6-8] and Energy Recovery Linac (ERL) [9]. However, long-term drifts and uncertain individual plate-twisting motions were not negligible to keep the phase masks of the intended square pulses.

## 2. Developments of genetic Algorithms for Deformable Mirror

The laser spatial profile was adaptively optimized with a genetic algorithm for a DM that consists of an aluminium-coated, multilayer silicon nitride membrane and 59 small mirror actuators behind the reflective membrane with a center-to-center distance of 1.75 mm between the actuators (left in Fig. 2). The reflective membrane is protected with MgF<sub>2</sub> coating to maintain reflectivity at about 80% in the UV region. Adjusting voltages between the control electrodes on the boundary actuators results in fine adjustment of each mirror actuator; the adjustable region of the control voltages is between 0 and 250 V in steps of 1 V, making it possible to shape the arbitrary spatial profiles for a total of 250<sup>59</sup> (~10<sup>141</sup>) deforming possibilities. However, since such high adjustability makes manual as well as simple algorithm adjustment impossible, this spatial shaping method with adaptive optics needs a sophisticated algorithm. Under the collaboration with F. Matsui (Industrial Technology Centre of Fukui Prefecture), we developed software based on a genetic algorithm to adaptively optimize DM deformation.

The set of the voltages of all DM-electrodes is treated as chromosomes in this software. A closed loop system is essential for a DM to adaptively optimize the laser's spatial profile. I used a PC to control the electrode voltage of the DM and to measure the spatial profile with a laser profile monitor (LBA300-PC, Spiricon Inc.).

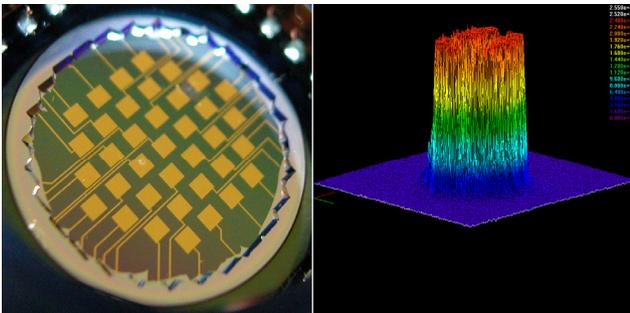


Figure 2. Result of spatial profile optimized to flattop (right) with a 59-ch DM: Mirror actuators behind the reflective membrane of a 37-ch type DM is shown in left as an example. Maximizing the fitting function consisted of laser profiling data analyzed with LBA300-PC, one of the best voltage sets applying to DM-actuators are searched by means of a metaheuristic method based on a genetic algorithm.

Laser light is reflected with deformation by the DM and monitored with a laser profile monitor, whose analyzing program can provide many parameters to evaluate the beam profile characteristics. I chose useful parameters to evaluate the flattop profiles and made a fitting function for the developed a genetic algorithm to optimize the profile toward an ideal flattop. The fitting function is a linear combination of flattop shaping parameters with certain optimal weights for fast convergence (see ref [2] for details). The value of this fitting function is returned as feedback to control the deformable mirror with the genetic algorithm. As a result, the laser profile on the cathode surface was spatially shaped as a quasi-flattop profile (right in Fig. 2). The laser spatial profile was remarkably improved by this shaping technique.

## 3.1. Square Temporal Shaping (Chirped UV Pulse Stacking)

Low-emittance generation experiments require keeping cathode laser spot sizes and bunch charge densities with varying longitudinal (temporal) square bunch lengths. Therefore, I developed several pulse stacking systems to provide several different total bunch lengths of stacked square pulses. To avoid the interference caused by stacking, orthogonally polarized chirped pulses are alternatively stacked with an optical delay. The optical delay period should be 1.2~1.3 times longer than the micro chirped Gaussian pulse duration to generate a precisely homogeneous electron bunch at the cathode. This method, which introduces additional chirp to avoid interference is referred to as "chirped pulse stacking." In 2007, we installed a new UV pulse stacking system [5] that consisted of four birefringent Alpha-BBO crystal rods (Fig.3 (B)) to fix the optical delays between neighboring micro chirped pulses in the previously developed mechanical pulse stacker (Fig.3 (A)) [2]. The angle of rotation of each crystal axis against incident polarization is 45° to make twin pulses. Then a pulse train with equivalent intervals is connected smoothly with pulse stretching controlled in chirping. These Alpha-BBO crystal rods can be used as a pulse stacker in the super broadband wavelength region (189–3500 nm).

## 3.2. Homogeneous connection at the cathode with adaptive AO-modulator

To generate a long square pulse without any timing gap or overlap, optical delays in each birefringent crystal, which are ~20% shorter than the micro Gaussian pulse duration, are applied to generate a precisely homogeneous electron bunch at the cathode. Micro pulse lengths  $T$  [fs] at the cathode stretched by the dispersion of the transparent materials for UV-laser in pulse stackers and transportation are estimated by the following formula, where no nonlinear process is assumed to occur in the optical elements:

$$T = t_0 \sqrt{1 + \left(4 \cdot \ln 2 \cdot GDD / t_0^2\right)^2} \text{ [fs]},$$



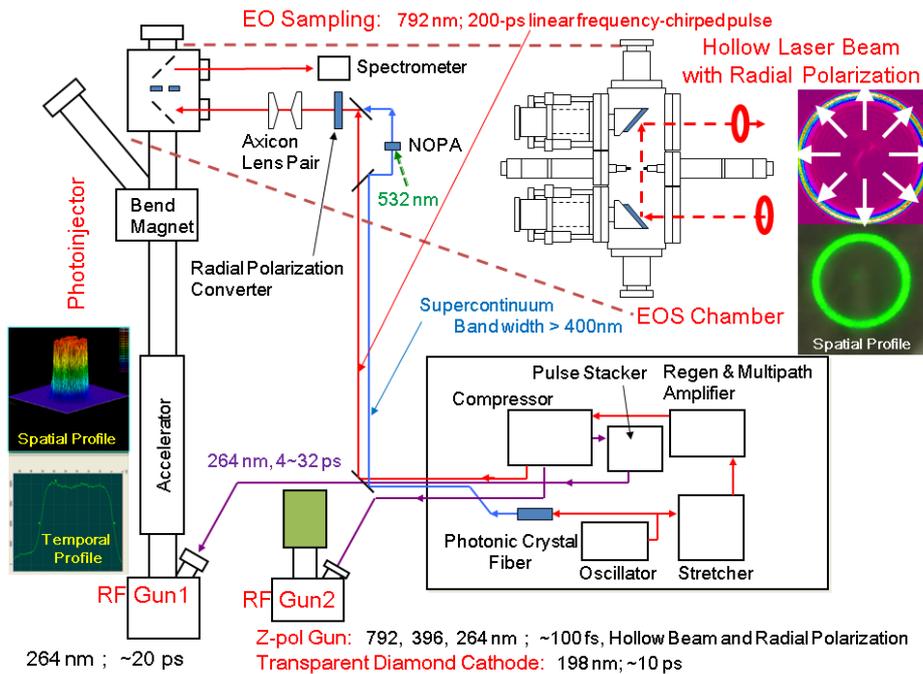


Figure 5. The present laser light distributions with swiching ATA system in the accelerator shird room at advanced photoinjector test facility in Spring-8 (Photo-cathode illumination at the test photoinjector: 3D- cylindrically shaped 4-32 ps pulse with DM and pulse stacker @264 nm; Photo-cathode illumination at the RF gun 2: radial or athmuthal polarization @264, 396, 792 nm; Probe laser for 3D-EOS: linear frequency-chirped 200-ps pulse and radial polarization @ 792 nm).

weights. As the target laser profiles, flattop profile for photo-cathode illumination, and hollow beam profile of a probe laser for single-shot 3D EO-sampling (EOS) monitor [12-13]. The present laser distributions are shown in Fig. 5. ATA has been successful to tune the laser automatically to each experimental station downstream.

## 5. Summary

The metaheuristic algorithm is useful to find one of the best solutions as acceptable as possible on each occasion. Tuning laser is one of the effective cases to apply such a sophisticated algorithm. The metaheuristic laser tuning system is expected to save our human resources and time for the laser maintenance and preparation in user's experiments. I have shown successful results on a genetic algorithm to optimize spatial (transverse) laser profiles and a hill climbing method extended with a fuzzy set theory to choose one of the best laser alignments automatically for each requirement at the experimental points downstream.

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